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PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:

Peter Hopper et al.

Appln. No.: 10/727,451

Filed: December 3, 2003

For: METHOD OF FORMING A DUAL  
DAMASCENE METAL TRACE WITH  
REDUCED RF IMPEDANCE RESULTING  
FROM THE SKIN EFFECT

Group Art Unit: 2812

Examiner: Nguyen, Ha T.

AMENDMENT IN RESPONSE TO OFFICE  
ACTION MAILED SEPTEMBER 29, 2004

INTRODUCTORY COMMENTS

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Official Action mailed September 29, 2004, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper; and

**Remarks** which begin on page 7 of this paper.

AMENDMENT IN RESPONSE TO  
OFFICE ACTION DATED SEPTEMBER 29, 2004

Atty. Docket No. 100-18011  
(P05268-D01-C1)